

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

**In re application of:**

Thomas A. Figura, Kevin Donohoe, & Thomas Dunbar

## § Group Art Unit:

Serial No.:

§ Application Examiner:

Filed: December 22, 1999

§ Atty. Docket: 94-0280.04

# Title: USE OF A PLASMA SOURCE TO FORM A LAYER DURING THE FORMATION OF A SEMICONDUCTOR DEVICE

§ Application Examiner:  
§ Atty. Docket: 94-0280.  
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Pres. Andt  
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Linda  
B.

## PRELIMINARY AMENDMENT

Assistant Commissioner for Patents  
Washington, D.C. 20231

Dear Sir:

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I HEREBY CERTIFY THAT THIS PAPER IS BEING DEPOSITED WITH  
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COMMISSIONER FOR PATENTS, WASHINGTON, D.C. 20231  
  
Signature

After awarding this application the benefit of the filing date of the great-grandparent application, filed June 2, 1995, please amend the accompanying continuation application as follows:

## IN THE SPECIFICATION

After the title, please include the following --

## RELATED APPLICATIONS

This application is a divisional of a pending U.S. application, serial number 09/046,835, filed on October 24, 1997; which is a continuation of U.S. application serial number 08/787,453, filed January 22, 1997 and issued on September 7, 1999 as U.S. Patent No. 5,950,092; which is a continuation of U.S. application Serial Number 08/458,861, filed June 2, 1995 and now abandoned. --